

18 Dec 02
2002077162



162162

(12) INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(19) World Intellectual Property Organization
International Bureau



(43) International Publication Date
31 January 2002 (31.01.2002)

PCT

(10) International Publication Number
WO 02/09103 A1

(51) International Patent Classification⁷: G11B 7/26

(21) International Application Number: PCT/NL01/00472

(22) International Filing Date: 25 June 2001 (25.06.2001)

(25) Filing Language: Dutch

(26) Publication Language: English

(30) Priority Data:
1015524 26 June 2000 (26.06.2000) NL

(71) Applicant (for all designated States except US): OTB
GROUP B.V. [NL/NL]; Dillenburgstraat 29, NL-5652
AM Eindhoven (NL).

(72) Inventors; and

(75) Inventors/Applicants (for US only): HENDRIKS, Chris-
tian, Etienne [NL/NL]; Busweg 28, NL-5632 PM Eind-
hoven (NL). TACKEN, Roland, Anthony [NL/NL]; Jan
Tooropstraat 22, NL-5642 AK Eindhoven (NL).

(74) Agents: PRINS, A., W. et al.; c/o VEREENIGDE, Nieuwe
Parklaan 97, NL-2587 BN The Hague, NL-5612 LV Eind-
hoven (NL).

(81) Designated States (national): AE, AG, AL, AM, AT, AU,
AZ, BA, BB, BG, BR, BY, BZ, CA, CH, CN, CO, CR, CU,
CZ, DE, DK, DM, DZ, EC, EE, ES, FI, GB, GD, GE, GH,
GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC,
LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW,
MX, MZ, NO, NZ, PL, PT, RO, RU, SD, SE, SG, SI, SK,
SL, TJ, TM, TR, TT, TZ, UA, UG, US, UZ, VN, YU, ZA,
ZW.

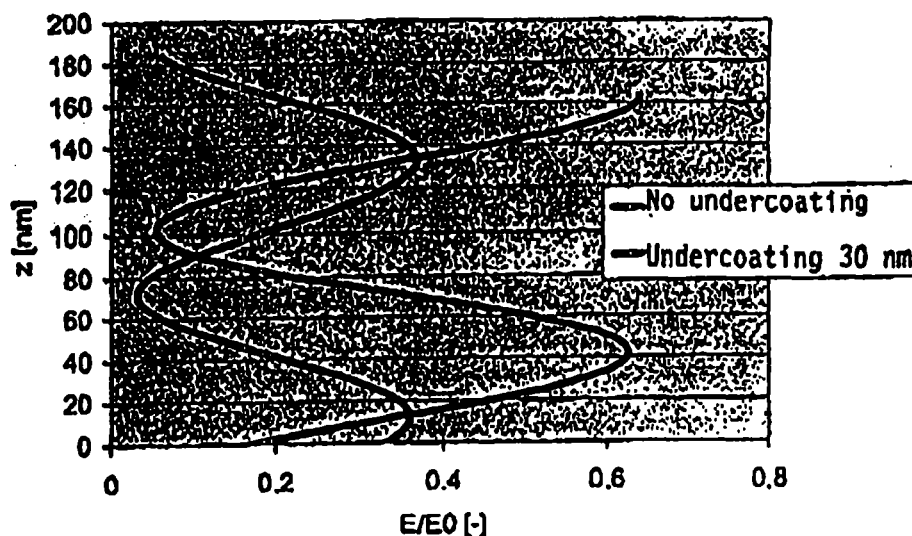
(84) Designated States (regional): ARIPO patent (GH, GM,
KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZW), Eurasian
patent (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European
patent (AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE,
IT, LU, MC, NL, PT, SE, TR), OAPI patent (BF, BJ, CF,
CG, CI, CM, GA, GN, GW, ML, MR, NE, SN, TD, TG).

Published:

— with international search report

For two-letter codes and other abbreviations, refer to the "Guid-
ance Notes on Codes and Abbreviations" appearing at the begin-
ning of each regular issue of the PCT Gazette.

(54) Title: A METHOD FOR MANUFACTURING A SUBSTRATE FOR USE IN A STAMPER MANUFACTURING PROCESS,
AS WELL AS A SUBSTRATE OBTAINED BY USING SUCH A METHOD



(57) Abstract: The present invention relates to a method for manufacturing a substrate for use in a stamper manufacturing process. The present invention furthermore relates to a substrate which is used in a stamper manufacturing process and to a method for manufacturing a stamper to be used in producing optical discs, comprising the exposing, developing and heating of a photosensitive film that has been coated onto a substrate.

WO 02/09103 A1



ACTION